

Title (en)
ELECTROLYTIC BATH FOR ELECTROPLATING AND PROCESS THEREOF

Title (de)
ELEKTROLYTISCHES BAD FÜR DIE GALVANISCHE ABSCHIEDUNG UND VERFAHREN ZU DESSEN HERSTELLUNG

Title (fr)
BAIN ÉLECTROLYTIQUE POUR PLACAGE ET PROCÉDÉ DUDIT PLACAGE

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Application
EP 11754998 A 20110824

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• EP 2011004244 W 20110824

Abstract (en)
[origin: WO2012025226A1] The invention relates to an electrolytic bath for electrodeposition containing nickel salt, phosphoric acid, phosphonic acid, and boric acid in solution. The invention further relates to a method for producing an electrolytic bath comprising the following steps: a nickel salt, phosphoric acid, phosphonic acid, and boric acid are mixed; and nickel carbonate is added in order to increase the pH value.

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